

Janos H. Fendler

Nanoparticles and Nanostructured Films

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# Nanoparticles and Nanostructured Films

Preparation,  
Characterization and  
Applications

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# Preface

Small is not only beautiful but also eminently useful. The virtues of working in the nanodomain are increasingly recognized by the scientific community, the technological world and even the popular press. The number of research publications in this area has been increasing exponentially. Additionally, national and international biological, physical, chemical, engineering, and materials science societies and government agencies have been organizing workshops, meetings, and symposia around some aspects of nanoparticle research with increasing frequency. This burgeoning interest is amply justified, of course, by the unique properties of nanoparticles and nanostructured materials and by the promise these systems hold as components of optical, electrical, electro-optical, magnetic, magneto-optical, and catalytic sensors and devices.

The appearance of numerous review articles and books on nanoparticle research has helped the neophyte to digest the veritable information overload. No recent overview has appeared, however, to the best of our knowledge, that focuses upon the utilization of “wet” chemical and colloid chemical methods for the preparation of nanoparticles and nanostructured films. The purpose of the present book is to fill this gap by summarizing current accomplishments in preparing and characterizing nanoparticles and nanostructured films and to point out their potential applications. Versatility, relative ease of preparation and transfer from the liquid to the solid phase, convenience of scale-up, and economy are the advantages of the chemical approach to advanced materials synthesis.

Electrochemistry has reached sufficient maturity and sophistication to be used for the layer-by-layer deposition of nanoparticles and nanoparticulate films. In Chapters 1 and 3 the state-of-the-art electrodeposition of quantum dots, superlattices, and nanocomposites is surveyed. Chemists have plenty to learn from mother nature. Much of the work on template-directed nanoparticle growth is inspired by biomineralization, the oriented growth of inorganic crystals in biomembranes. Advantage has been taken of organized surfactant assemblies that mimic the biological membranes to grow nanoparticles and nanoparticulate films. Chapters 2 and 4 highlight the growth of metallic, semiconducting, and magnetic nanoparticles under monolayers and within the confines of reverse micelles. More rigid templates have also been employed for nanoparticle preparations. This approach is illustrated

for such diverse templates as opal (Chapter 13), nanoporous membranes (Chapter 10), and zeolites (Chapter 17). Chapter 7 emphasizes the use of block copolymer micelles as hosts for generating metallic nanoparticles.

The recent attention to porous silicon nanoparticles has been prompted by their demonstrated photoluminescence and electroluminescence, as well as by their promise to function as optical interconnects and chemically tunable sensors, which require passive surfaces that are stable to oxidation yet are able to conduct current efficiently. Chemical and plasma-induced silicon nanocluster formation and growth are examined in Chapters 5 and 8. The potentially important, albeit as yet unexplored fullerene nanoparticles and their two-dimensional crystal growth are surveyed in Chapter 6.

Nanoparticles themselves can be used as building blocks for two-dimensional arrays and/or three-dimensional networks. They can also be derivatized and treated as if they were simple molecules. This approach should lead to the type of hetero-supramolecular structures that are illustrated in Chapter 16. Such complex chemistries must go hand-in-hand with an improved understanding of surface and colloid chemical interactions. Some aspects of these are discussed in Chapters 11 and 12.

Exploitation of nanoparticles and nanostructured materials requires an appreciation of electron and photoelectron transfer mechanisms therein. Chapter 9 presents a well balanced view of the electron transfer processes in nanostructured semiconductor thin films while Chapter 14 discusses charge transfer at nanocrystalline metal, oxide–semiconductor interfaces and its relation to electrochromic–battery and photovoltaic–photocatalytic interfaces. Significantly, as summarized in Chapter 15, nanoparticles provide us with the possibility of monitoring, and ultimately exploiting, single electron transfer events.

An attempt has been made in the last chapter to provide the newcomer with handy “recipes” for the preparation of nanoparticles and nanostructured films as well as to summarize current accomplishments and future prospects in this intellectually fascinating and highly relevant area of research. Inevitably, current activities soon become “past achievements”, and interested readers will have to acquaint themselves with the latest results as they appear in primary publications and as they are disseminated at scientific meetings. Chapter 18 also lists selected data on the properties of the most frequently used bulk semiconductors in order to permit much needed comparisons between the bulk and size-quantized materials.

I am grateful to all the contributing authors who took time from their busy schedule to write their chapters and thus to share their expertise with the scientific community. I also thank Dr. Peter Gregory and Dr. Jörn Ritterbusch, the Editors at WILEY-VCH, and their staff for initiating this project and for providing enthusiastic support throughout the various stages of publication.

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